| | Fall | 2013 | HW#Z | Solution | |
|------------------------|--------------|-------------|------------------|--|-------------|
| 200 | 2.10 | | | - | 20 Jan 198 |
| - Calculation | | | | | |
| electron | 1= - ME = 1 | (700 cm2 | Ns) (2500- | $(m) = (1.75 \times 10^{-1})$ | os cm |
| holk | Vh= Un & = 1 | (250cm2 | V8) (2500 % | m)= 625×10 | 3 <u>CM</u> |
| | , | | | | |
| e tection currently | jn=-g.n.ve | = = (1.602× | 10-18C) (1017 (W | -3)(-1,75×106 cm |)= 28000 to |
| | 9 | | 19/(1/3 -3) | (6-5 403 CM) | |
| hole current | jp=q.b.1 | n = (1,602x | (0,5) (0,5m2) | (625×10° =)= | 1×10-10 A |
| | 9 | | | erigia a sir con accessor | |
| | 2,16 | * 1 | | 1 | (95) |
| | | , | | | |
| | 10= 9 Vhp = | (1,602×10 | | (10 m/s) | - 6 |
| , | = | 1.60 × 100 | A/cm2 | - | |
| | 200 | | | Prof. | 7. ** \$2. |
| | I= ip. A= | (1,60×107 | Forz (Jun |) (25 µm) (10 | gem 2 |
| | | (8) | 7 | Browners | , , |
| | Ip = | 4 A | 1 | interestant report | |
| | | | 1 | | |
| | | | | | |
| | | | | 1 | 1 1 |
| | | | | 100 Miles (100 Miles (| |
| | | | | | 1 |
| | 18 | | | 4 | 1 |
| | | | · | and the second | - |
| 7 | | | | | |
| | | | | - | |
| | | | | | |
| | | | 0 | | |
| | | | | 1 | |

2,3 NA>NO, therefore p-type use equation 2.12 p= (NA-NO)+ \((NA-NO)^2+4n^2 p= (9×1015cm-3)+ √(9×1015cm-3)2+4(5×1013cm-3)2 $p = 9 \times 10^{15} \text{ (m}^{-3})$ $h = \frac{11^2}{10^{15} \text{ cm}^{-3}} = \frac{(5 \times 10^{13} \text{ cm}^{-3})^2}{(9 \times 10^{15} \text{ cm}^{-3})} = \frac{12 \cdot 78 \times 10^{11} \text{ cm}^{-3}}{(10^{15} \text{ cm}^{-3})^2}$ Above always works. Alternative Solution: use equation 2,10 $N_0 + p - N_A - n = 0$ $N_A - N_D - p + \frac{n^2}{p} = 0$ However $\frac{n^2}{p} \ll N_A, N_D, p$, therefore reglect it true if $N_A-N_D >> n_1$ $N_A-N_D-p\approx 0$ $p\approx N_A-N_D=\frac{q\times 10^{15} \text{ cm}^{-3}}{q}$ $n = \frac{n!}{p} = \sqrt{2.78 \times 10^{11} \text{ cm}^{-3}}$

2,34 Because the silicon is doped with acceptors, it is p-type using equation 2,10 NA-No+n-p=0 NA >> n, 210 cm 3 @ 300K, Herefore NA, P7>n
and px NA = 2,5 × 1018 cm 3 $n = \frac{n^2}{p} = \frac{(1.10^{10} \text{ cm}^3)^2}{2.5 \times 10^{18} \text{ cm}^3} = \frac{40 \text{ cm}^3}{10^{18} \text{ cm}^3} = \frac{1}{10^{10}}$ from Fig. 2.8: Mn= 92+ 12+0 = 173 cm2/Vs Mp=48+ 1+(NA+NO 10.76= 73cm2/15 N+= NA+ND=NA= 2,5×1018 cm-3 P= = = qnun = qppp = (1.602x10-12)(2.5x1018(M-3)(734/5) nexp P = 30.5 × 10-3 1. cm

| | | 2.45 | |
|-----------|-----|---|----------------|
| 7 | | | |
| . \ | | Part A | |
| i i | | - Since sample is only signed w/ acceptors, most likely PXNA>>h. Assume this and check as | |
| All | | most likely px NA>> h. Assume this and check as | sumption later |
| | | is is greek "tho" for resistivity | |
| | T (| Sis greek file | |
| | U | b= = abre db. nb(N+=N*=b) | |
| | 2 | this is toleration 447 cm²/Vc | |
| | (3) | Mp (N+=p) = 48+ 447 cm²/Vs from fig | we 2.8 |
| | | A. A. | |
| <u>()</u> | - | - Solve equation (1) substating equation (2) for use $P = 1.2$ cm and $N = N_A = P$ this gives $P = 1.67 \times 10^{16}$ cm ³ = N_A for P | p(NT) |
| | | | - 1 |
| | - | bususe p=1.67 ×1010 cm ⁻³ , our assumption of pxN _A >> M is valid | |
| | | 10% 10A - 3 F1 13 19110 | |
| | | Now solve evention (1) again for D=0,25 | R.cm |
| | | Now, solve evention () again for p=0.25 this gives p=1.12 × 10 ¹⁷ cm ⁻³ NA for p=0.2 | 5 s.cm |
| | _ | subtract the two values of NA for the two | resistivities |
| | | NAZ-NAI = 1,12 ×1017 cm3 - 1,67 × 1018 cm3 = 9,1 | 50×1016-3 |
| | 1- | Therefore 9.50×1016 cm-3 boron depart atoms must | - be |
| | | Therefore 9.50×1016 cm ⁻³ boron depart atoms must added to change the resistivity as desired. | |
| | | | |
| | | | L |

2.45 part B From part A, the p-type doping of the original sample is NA=1.67 × 1016 cm⁻³ To reduce the resistivity using doners, the Sample must be counter-doped w/ ND> NA.

Therefore the sample will change to n-type.]

Also, therefore, ND-NA>>n; and nxND-NA>>p,

so we solve the following: 3) px qn ma(NT=No-NA=n) $\Theta_{\mu}(n) = 92 + \frac{1270}{1 + (\frac{N_{7} = N_{0} - N_{A} = n}{1.3 \times 10^{17} \text{ cm}^{-3}})} \frac{\text{cm}^{2}/\text{Vs}}{2.8}$ Solve equation (3), substituting for equation (4)
with $D = 0.25 \Omega$.cm, this gives $N = N_0 - N_A = 2.16 \times 10^{10} \text{ cm}^{-3}$ Therefore ND= n+NA= 2,16×1016 cm-3+1.67×1016 cm-3

ND= 3.82×1016 cm-3 No= 3.82 10 cm3 must be added to the Silicon to achieve 0.25 s.cm resistivity using donorsatoms

 $\int_{h} = -g D_{n} \left(-\frac{dn}{dx} \right)$ equation 2.15: Dn= KT Un (for non-degenerate semiconductor) $\frac{dn}{dx} = \frac{10^{18} \text{ cm}^{-3}}{\text{NB}} = \frac{10^{18} \text{ cm}^{-3}}{0.5 \text{ µm}} \cdot \left(\frac{10^{6} \text{ µm}}{100 \text{ cm}}\right) = 2 \times 10^{22} \text{ cm}^{-4}$ Mn=350 cm2/Vs (given) KT = 0.0259 eV. 1.602×1019 J at T=300K (ROOM TEMP) Jn= 0.0259 eV. (1.602×10-9) (350 cm²/Vs) (2×1022 cm4) Jn= 29000 A/cm² (units et = 4 . Cm² · cm² + A2)

2,51 NA(X) = 10"+ 1018 exp(-104x) X in cm Because NA>>n; paNA>>n Total current must equal zero in equilibrium In diffusion + Jp, diffusion + In, drift + Jp, drift = 0 (egit) because nexp, Indistrución and Injurist ~ OA 50 Jp, diffusion + Jp, drift = 0 (eq. 2.17) Jp airrusion = Tgypp V+ dx, Jp,drift = qppp & - Because de à diva # 0, there is a diffusion current.

Therefore there must be a built un electric

field & 50 that 5total = 0 - What is & at x=0 mm! - de = 1018.104. exp(-104x) = -102 exp(-104x) cm4 $\frac{dN_A}{dx}|_{x=0} = -10^{22} \text{ cm}^{-1}$ Jordistusion - Jeanist = 0 => -quplate = qpupe 3 1-3 = 3 E = 7 dp So $E = \frac{\sqrt{T}}{p} \frac{dp}{dx} \approx \frac{\sqrt{T}}{N_{A}(x)} \frac{dN_{A}}{dx} = \frac{0.0259 \, \text{V}}{10^{18} \, \text{cm}^{-3}} = -10^{22} \, \text{cm}^{-1} = -259 \, \frac{\text{V}}{\text{cm}}$ At X=0 mm, There is a built in electric field of - 259 cm

2,51 (certinued) What is electric field E at x= 5 mm! de ~ dNA | x=5um = -1022 exp (-104 (5µm x 100cm)) (m-4 = -6.74×10-21 cm-4 A/(X=5µm) = 10"+10" exp(-10" (5µm 100m))
= 6.84 × 10" cm 3

E = 15. dp 2 VT dNA

NA(5µm) dx k=5µm = 0.0259V (-6.74×10-21 cm-4) E = - 25500 cm At x=5µm, there is a built in electric field at of -25500 cm (minus sign indicates electric field is in minus x direction.)